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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|-----------------|-------------|----------------------|---------------------|------------------|
|-----------------|-------------|----------------------|---------------------|------------------|

09/707,435

11/06/2000

Debra D. Wawro

UTSL:058US/MTG

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05/31/2005

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EXAMINER

KAO, CHIH CHENG G

ART UNIT

PAPER NUMBER

2882

DATE MAILED: 05/31/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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| | | | |
|------------------------------|---------------------|--------------|--|
| Office Action Summary | Application No. | Applicant(s) | |
| | 09/707,435 | WAWRO ET AL. | |
| | Examiner | Art Unit | |
| | Chih-Cheng Glen Kao | 2882 | |

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 21 March 2005.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-12, 14-35, 38-51 and 61-66 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-12, 14-35, 38-51 and 61-66 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 15 August 2003 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input checked="" type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>2/25/05</u> | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Claim Objections

1. Claims 11, 15, and 35 are objected to because of the following informalities, which appear to be minor draft errors creating grammatical issues.

In the following format (location of objection; suggestion for correction), the following suggestions may obviate their respective objections: (claim 11, line 1, “comprises a dielectric”; inserting - -material- - after “dielectric”), (claim 15, line 9, “at least one permittivity”; inserting - -of- - after “one”), and (claim 35, line 8, “at least one permittivity”; inserting - -of- - after “one”).

For purposes of examination, the claims have been treated as such. Appropriate correction is required.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

2. Claims 1, 3, 4, 6, 8-12, 14, 15, 23, 24, 26, 28-35, 38, 46, 62-64, and 66 are rejected under 35 U.S.C. 102(b) as being anticipated by Magnusson et al. (US Patent 5598300).

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3. Regarding claims 1, 15, 35, and 38, Magnusson et al. discloses system and method comprising a waveguide grating device (fig. 1) comprising at least one waveguide, through which a signal having at least one wavelength may be propagated (figs. 13 and 14), having a proximal end and a distal end having an endface (fig. 1, d_1), and a guided-mode resonance waveguide grating (fig. 1, d_{n-1} to d_{n+1}) fabricated on the endface of the at least one waveguide (fig. 1, d_1), the guided-mode resonance waveguide grating having at least one waveguide layer (fig. 1, d_{n-1}) and at least one grating layer (fig. 1, d_n), the waveguide grating also having a plurality of variable parameters including at least one of permittivity of the at least one grating layer, permittivity of the at least one waveguide layer, periodic structure of the at least one grating layer, grating fill factor of the at least one grating layer, thickness of the at least one waveguide layer, and the thickness of the at least one grating layer (col. 7, lines 23-27, and fig. 3a), the periodic structure of the at least one grating layer having a period less than the at least one wavelength of the signal (col. 4, lines 60-67).

4. Regarding claims 3 and 23, Magnusson et al. further discloses wherein the at least one waveguide is rectangular in shape (fig. 1, d_1).

5. Regarding claims 4, 6, 24, 26, and 46, Magnusson et al. further discloses wherein the at least one grating layer and the at least one waveguide layer comprise a dielectric material (col. 2, lines 24-26, and col. 12, lines 48-50).

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6. Regarding claims 8, 28, and 63, Magnusson et al. further discloses wherein the at least one grating layer and the at least one waveguide layer comprise the same layer (fig. 1, d_1).

7. Regarding claims 9, 29, and 64, Magnusson et al. further discloses wherein the at least one grating layer and the at least one waveguide layer comprise different layers in contact with each other (fig. 1, d_{n-1} and d_n).

8. Regarding claims 10-12 and 30, Magnusson et al. further discloses at least a third layer comprising a dielectric material (col. 2, lines 24-26, and col. 12, lines 48-50) or metal (col. 12, lines 48-50) in contact with the at least one waveguide layer (fig. 1, d_{n-2}).

9. Regarding claims 14 and 31, Magnusson et al. further discloses a third layer (fig. 1, d_{n+1}) in contact with the at least one grating layer (fig. 1, d_n).

10. Regarding claims 32-34, a recitation with respect to the manner in which a claimed apparatus is intended to be employed does not differentiate the claimed apparatus from a prior art apparatus satisfying the claimed structural limitations.

11. Regarding claims 62 and 66, Magnusson et al. further discloses the grating and waveguide layers having different permittivities (fig. 1).

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12. Claims 1-4, 6, 9, 38, 39, 46, and 47 are rejected under 35 U.S.C. 102(e) as being anticipated by Farah (US Patent 5891747).

13. Regarding claims 1 and 38, Farah discloses a device and method comprising at least one waveguide having an end and endface (fig. 4b, #6) and a waveguide grating on the endface having at least one waveguide layer and at least one grating layer (fig. 4b, #43).

14. Regarding claims 2 and 3, Farah further discloses at least one waveguide being a fiber (fig. 4a, #6) or rectangular in shape (fig. 14, #86).

15. Regarding claims 4, 6, and 9, Farah further discloses the at least one grating layer and waveguide layer being a dielectric material (col. 13, lines 5-7) and being different layers in contact with each other (fig. 4b, #6 and 43).

16. Regarding claim 39, Farah further discloses cleaving (col. 5, lines 15-17).

17. Regarding claims 46 and 47, Farah further discloses etching at least one dielectric grating (col. 14, lines 62-65).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

18. Claims 2 and 22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. as applied to claims 1 and 15 above, and further in view of Dawes et al. (US Patent 6488414).

Magnusson et al. discloses a device and system as recited above.

However, Magnusson et al. does not disclose at least one waveguide being a fiber.

Dawes et al. teaches at least one waveguide being a fiber (title and fig. 5).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the device and system of Magnusson et al. with the fiber of Dawes et al., since one would be motivated to make such a modification to send an optical signal over a longer distance with less signal loss.

19. Claims 5, 7, 25, 27, and 40 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. as applied to claims 1, 15, and 38 above, and further in view of Tibuleac ("Characteristics of Reflection and Transmission Waveguide-Grating Filters").

Magnusson et al. discloses a device, system, and method as recited above.

However, Magnusson et al. does not disclose wherein at least one grating layer and at least one waveguide layer comprise a polymer.

Tibuleac teaches wherein at least one grating layer and at least one waveguide layer comprise a polymer (page 94, lines 1-3).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the device, system, and method of Magnusson et al. with the polymer of Tibuleac, since it would be within the general skill of a worker in the art to select a known material on the basis of its suitability. One would be motivated to make such a modification to more easily shape the layer and create a stronger material.

20. Claims 16-19 and 21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. as applied to claim 15 above, and further in view of Liu et al. ("High-efficiency guided-mode resonance filter").

Magnusson et al. discloses a system as recited above. Magnusson et al. further discloses a signal propagating through at least the one waveguide, wherein after the signal is propagated, it contacts the grating and is reflected from the grating in whole or in part depending at least partially upon the plurality of variable parameters (fig. 2B, "R").

However, Magnusson et al. does not disclose a laser source, which is a continuous wave source, and an operationally coupled photodetector comprising the human eye.

Liu et al. teaches a laser source (fig. 2, "laser"), which is a continuous wave source, and an operationally coupled photodetector (fig. 2, detector) comprising the human eye (fig. 2, PC or looking at the output from the filter).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the system of Magnusson et al. with the laser source and detector of Liu et al., since one would be motivated to make such a modification to more easily measure the characteristics of the filter (fig. 2) as implied from Liu et al.

21. Claim 20 is rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. and Liu et al. as applied to claim 19 above, and further in view of Layton (US Patent 4753529).

Magnusson et al. as modified above suggests a system as recited above.

However, Magnusson et al. does not disclose a detector comprising silicon.

Layton teaches a detector comprising silicon (col. 14, lines 10-15).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the system of Magnusson et al. as modified above with the silicon detector of Layton, since one would be motivated to make such a modification to reduce noise (col. 14, lines 4-15) as implied from Layton for a better signal.

22. Claims 39 and 47 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. as applied to claims 38 and 46 above, and further in view of Dawes et al. and Farah (US Patent 5891747).

Magnusson et al. discloses a method as recited above.

However, Magnusson et al. does not disclose cleaving an end to form an endface of at least one waveguide and etching.

Dawes et al. necessarily cuts an end to form an endface of at least one waveguide (col. 3, line 57) for adhering an optical element. Farah teaches cleaving (col. 5, lines 15-17) and etching (col. 14, lines 62-65).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the method of Magnusson et al. with the cutting of Dawes et

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al., since one would be motivated to make such a modification to make it easier to connect one component to another (fig. 2) as implied from Dawes et al.

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the method of Magnusson et al. as modified above with the cleaving and etching of Farah, since one would be motivated to make such a modification for more precise cuts (col. 5, lines 15-17) as implied from Farah.

23. Claim 41 is rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. and Tibuleac as applied to claim 40 above, and further in view of Dawes et al. and Grabbe (US Patent 5863449).

For purposes of being concise, Magnusson et al. in view of Tibuleac and Dawes et al. suggests a method as recited above.

However, Magnusson et al. does not disclose dipping.

Grabbe teaches dipping (col. 3, lines 30-40).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the method of Magnusson et al. as modified above with the dipping of Grabbe, since one would be motivated to make such a modification for more easily adding additional layers on the endface (col. 3, lines 30-40) as implied from Grabbe.

24. Claims 42-44 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al., Tibuleac, Dawes et al., and Grabbe as applied to claim 41 above, and further in view of Hobbs (WO 97/47997).

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Magnusson et al. as modified above suggests a method as recited above.

However, Magnusson et al. does not disclose holographic interferometry or photolithography patterning.

Hobbs further teaches holographic interferometry (Page 1, "Field of Invention") or photolithography patterning (Page 2, top paragraph).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the method of Magnusson et al. as modified above with the patterning techniques of Hobbs, since one would be motivated to make such a modification to produce periodic structures more accurately (Page 1, "Field of Invention") as implied from Hobbs.

25. Claims 45 and 48 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. and Tibuleac as applied to claims 40 and 38 above, and further in view of Levenson et al. (US Patent 5291574).

Magnusson et al. as modified above suggests a method as recited above.

However, Magnusson et al. does not disclose spin coating or sputtering.

Levenson et al. teaches spin coating or sputtering (col. 2, lines 33-36).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the method of Magnusson et al. as modified above with the spin coating or sputtering of Levenson et al., since one would be motivated to make such a modification to add layers more evenly (col. 2, lines 33-36) as implied from Levenson et al. for easier manufacturing.

26. Claims 49-51 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. as applied to claim 38 above, and further in view of Dimos et al. (US Patent 6096127).

Magnusson et al. as modified above suggests a method as recited above.

However, Magnusson et al. does not disclose thermal evaporation, electron-beam evaporation, or liquid phase epitaxy.

Dimos et al. teaches thermal evaporation, electron-beam evaporation, or liquid phase epitaxy (col. 1, lines 30-40).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the method of Magnusson et al. as modified above with the various depositing methods of Dimos al., since these methods are well known in the art. One would be motivated to make such modifications to deposit layers more evenly (col. 1, lines 30-50) as implied from Dimos et al.

27. Claims 61 and 65 are rejected under 35 U.S.C. 103(a) as being unpatentable over Magnusson et al. as applied to claims 15 and 35 above, and further in view of Magnusson et al. ("Guided-mode resonance Brewster filter").

Magnusson et al. ('300) discloses a device and system as recited above.

However, Magnusson et al. ('300) does not disclose the permittivities of the at least one waveguide and the at least one grating layer being the same.

Magnusson et al. (Letters) teaches the permittivities of the at least one waveguide and the at least one grating layer being the same (fig. 1, $n_s = n_{1L}$).

It would have been obvious, to one having ordinary skill in the art at the time the invention was made, to incorporate the device and system of Magnusson et al. ('300) with the same permittivities of Magnusson et al. (Letters), since one would be motivated to make such a modification for creating higher efficiency filters at Brewster angles (abstract) as implied from Magnusson et al. (Letters).

Response to Arguments

28. Objections to the claims in the Office Action mailed 9/21/04 have been withdrawn in light of the Amendment filed 3/21/05.

29. Applicants' arguments with respect to claims 1-12, 14-35, 38-51, and 61-66 have been considered but are moot in view of the new ground(s) of rejection. Applicant's arguments filed 9/21/04 have been fully considered but they are not persuasive.

Applicants argue that amending the claims to recite a guided-mode resonance waveguide grating is not a narrowing amendment. The Examiner disagrees. Amending gratings to be of the guided-mode resonance type, narrows the type of gratings that are being claimed. For example, a waveguide grating of Dawes et al. (fig. 1, #32) would not read on a guided-mode resonance waveguide grating, since the shape of the grating cannot be used to create guided-mode resonance. The amendment to the claims limits the claims to gratings having a structure that can create guided-mode resonance. Therefore, Applicants' arguments are not persuasive, and the amended claims necessitated a new ground(s) of rejection, which accordingly make this Office Action final.

Applicants argue that Farah only discloses a diffraction grating and fails to disclose or suggest a guided-mode resonance waveguide grating. The Examiner disagrees. Although Farah does not specifically recite the term “guided-mode resonance waveguide grating”, the grating of Farah still has the structure that reads on a guided-mode resonance waveguide grating.

Applicants further argue that there is no motivation to combine Dawes et al. with Magnusson et al. and combining the teachings of Magnusson et al. with those of Dawes et al. would change the principle operation of Dawes et al. The Examiner disagrees. As seen in Figure 5, Dawes discloses attaching an optical element to an end for the desired functionality of collimation. Substituting the optical element producing low sidebands of Magnusson et al. into Dawes et al. would create the same collimation effect with improved anti-reflectivity. Therefore, the combination is not improper and would not change the principle operation of Dawes et al.

In conclusion, Applicants’ arguments are not persuasive, and the prior art remains applicable to the claims.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period

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will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.


Any inquiry concerning this communication or earlier communications from the examiner should be directed to Chih-Cheng Glen Kao whose telephone number is (571) 272-2492. The examiner can normally be reached on M - F (9 am to 5 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ed Glick can be reached on (571) 272-2490. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).



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